REMARKS

Amendment of claim 6

It has been discovered that the previous amendment changed the punctuation from a semicolon to a comma in one member of the Markush group in claim 6. The change was not marked and was inadvertent. The amendment restores the original semicolon. No new matter has been added and no new issue is raised. Entry of the amendment puts the application in condition for allowance, or in better condition for appeal, and therefore entry of the amendment after final rejection is seen to be proper and is respectfully requested.

Claim Rejections

Claims 20-22, 26, 6-7, 9. 11, and 13-14 have been rejected as anticipated by Wang et al, US 6,465,067, and claims 23-25, 29-30 and 10 have been rejected as obvious from Wang et al taken in view of Forte et al, US 2003/0054161. The rejections are traversed. Reconsideration is requested.

The two rejections contain the same fundamental error.

Claim 20 pertains to passing a polymer composition through <u>an</u> opening. Claim 20 also recites varying an amount of crystallization modifier "in the polymer composition passing through <u>said</u> opening." Therefore all of the material being recited in claim 20 goes through the same opening.

Coextruded layers such as described in both Wang et al and Forte et al, are produced by passing polymer material through <u>different</u> openings. The different layers are not produced by passing through <u>an</u> opening as recited in claim 20. There is variation between polymer compositions passing through the <u>different</u> openings, but no teaching or suggestion to

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vary the polymer composition passing through "an opening" as required in claim 20.1

At least for the reason that the cited documents pertain to variations in material composition emitted from different openings, Wang et al does not anticipate claims 20-22, 26, 6-7, 9. 11, and 13-14, and the combination of Wang et al and Forte et al does not render obvious claims 23-25, 29-30 and 10. Withdrawal of the outstanding rejections and allowance of the application is respectfully requested.

Respectfully submitted,

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¹ Of course, it is possible to use the present invention with a coextrusion, but the recitations of claim 20 require that the layers be considered individually in such a case.